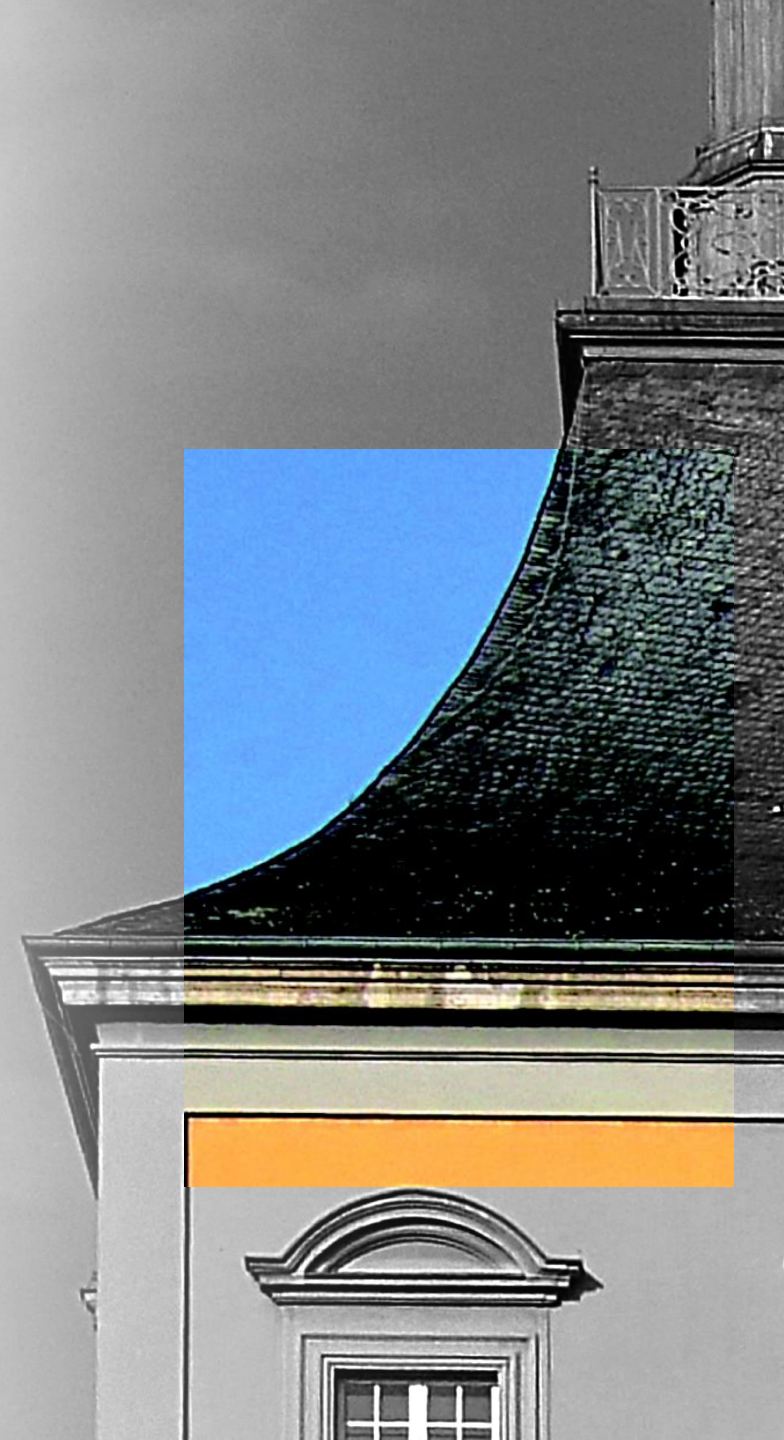


OBELIX

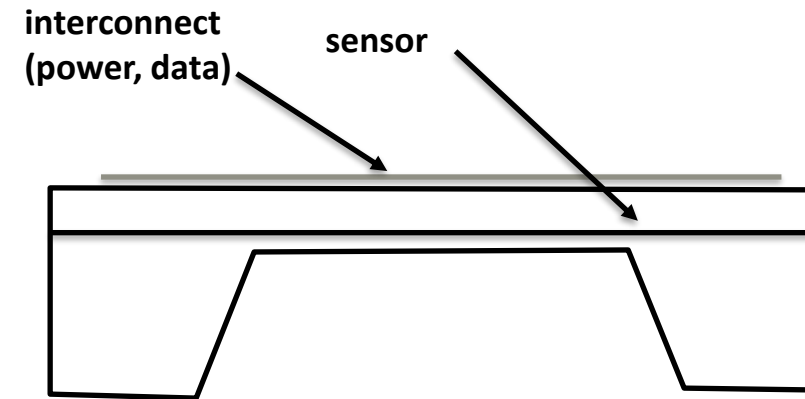
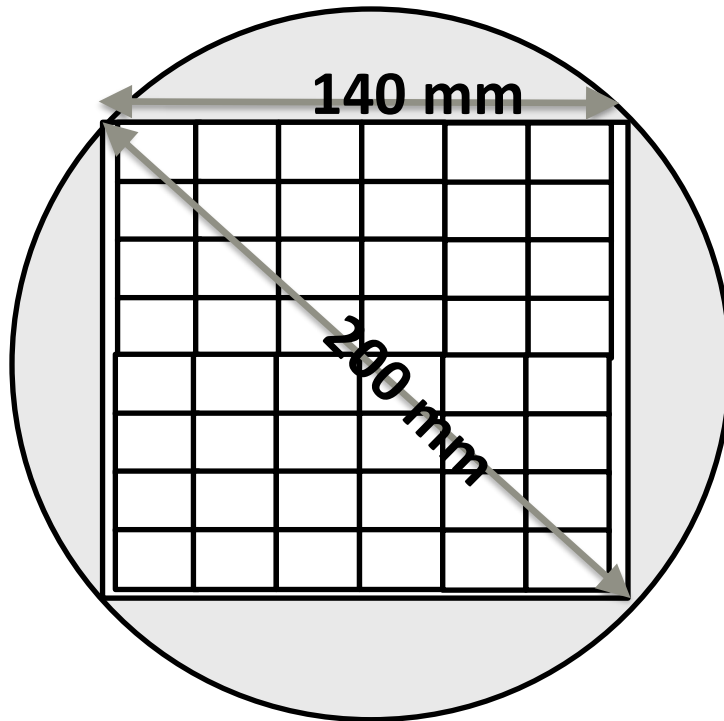
DESIGN

Tomasz Hemperek



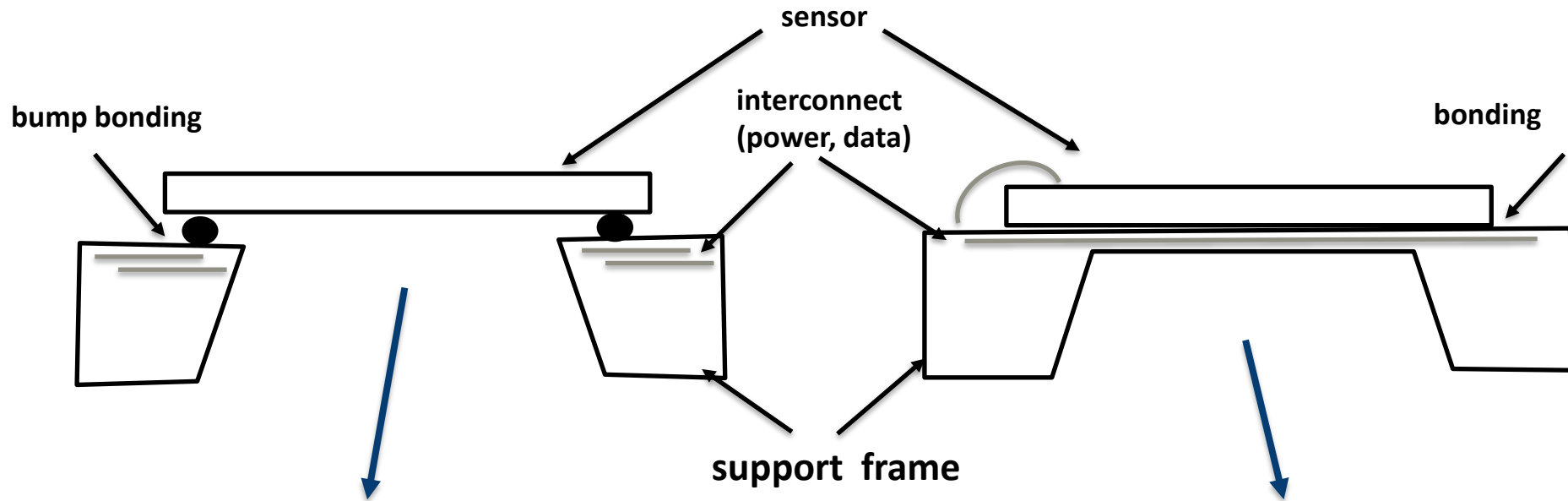
- In order to share layout we need clear legal situation (Tower + CERN).
- Digital design of Monopix2 can be shared immediately.

We need MoU?



- deposit RDL (1-2 metal system) (up to 5um Cu)
- etch selectively backside
- cut

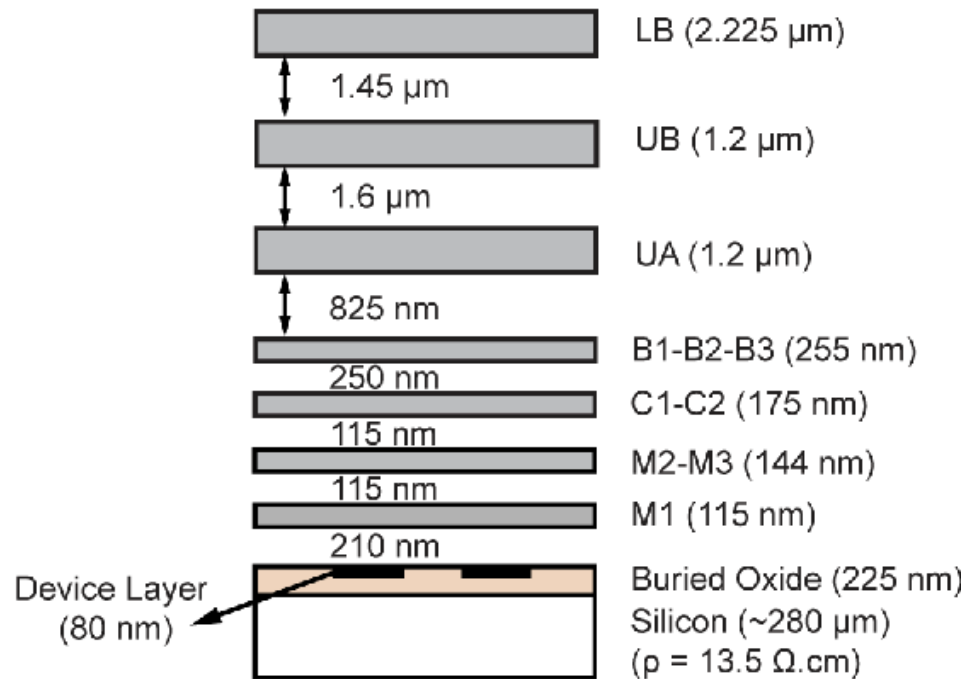
Need prototype for signal integrity etc. (need wafers)



Critical:
Flip-chip (release) thin chips after bonding

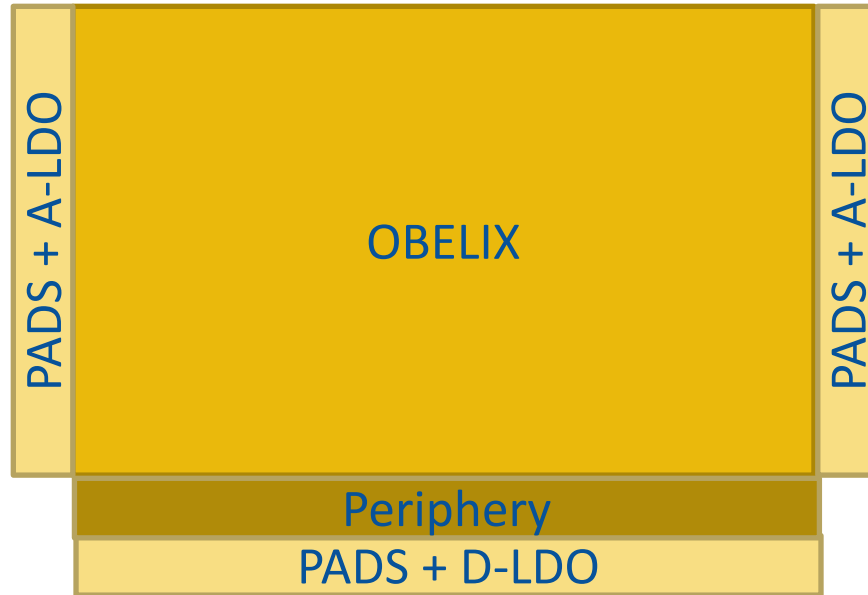
Critical:
Etch backside after bonding

Need checking/prototyping

!ARBITRARY PICTURE FROM INTERNET

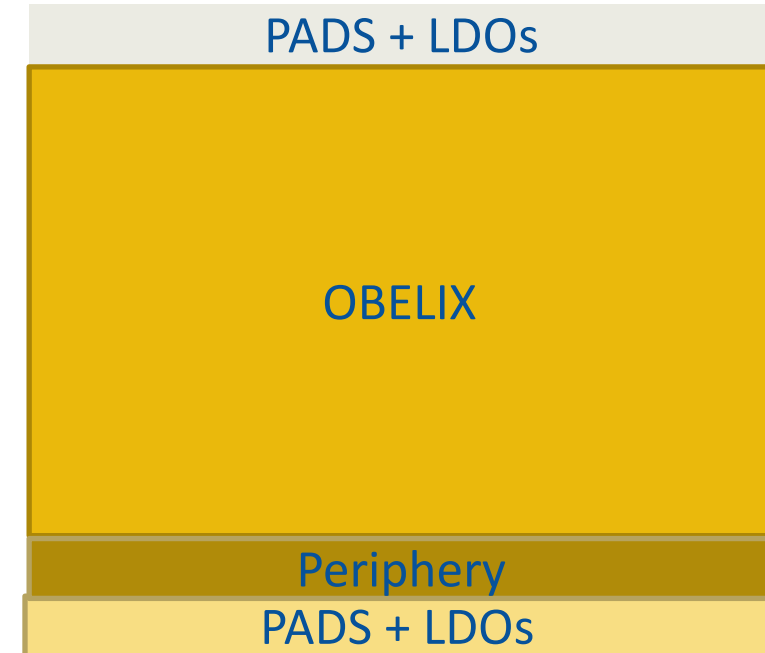
- There are multiple metal options including thick metal Cu, Al, RDL
- Need to know what is available in practice
- Carefully understand and pick most suitable
- Need **NDA** protected group to discuss this

Power from the sides



- Can use design as is*
- LDO + PADS <~ **150um (ACTION ITEM)**
- Power distribution from PADS to matrix

Power from bottom/top



- Mayor pixel redesign needed
- Metal stack choice is critical
- **ACTION ITEM: investigate voltage drop dependence on pixel/threshold)**

Group chat

https://chat.belle2.org/channel/vtx_upgrade_obelix